

Title (en)

SYSTEM AND METHOD FOR ADJUSTING DENTAL X-RAY EXPOSURE

Title (de)

SYSTEM UND VERFAHREN ZUR ANPASSUNG DER DENTALEN RÖNTGENBESTRAHLUNG

Title (fr)

SYSTÈME ET PROCÉDÉ POUR RÉGLER UNE EXPOSITION DENTAIRE AUX RAYONS X

Publication

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Application

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Citation (search report)

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- [A] JP 2005087281 A 20050407 - MATSUSHITA ELECTRIC IND CO LTD
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Designated contracting state (EPC)

AL AT BE BG CH CY CZ DE DK EE ES FI FR GB GR HR HU IE IS IT LI LT LU LV MC MK MT NL NO PL PT RO RS SE SI SK SM TR

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